Table 1

	Conditions	Amount of residual chlorine $\mu m$ g/cm $^2$ $10^{15}$ atoms/cm $^2$		After- corrosion	Symbols shown in Fig. 9
0	Etching only	0.92±0.06	16.0±1.0	Large	0
2	Downflow ashing using O <sub>2</sub> after ①	0.89±0.06	15.5±1.0	Large	•
3	Downflow ashing using O <sub>2</sub> +CF <sub>4</sub> after (	0.54±0.03 O	9.3±0.4	Small	*
<b>④</b>	Downflow ashing using O <sub>2</sub> +H <sub>2</sub> O after (	0.23±0.03 D	4.0±0.5	No	<b>♦</b>
6	Exposure to H <sub>2</sub> O after ② (30sec)	0.51±0.02	8.7±0.3	Small	<b>A</b>
6	Exposure to H <sub>2</sub> O after ② (90sec)	0.48±0.01	8.1±0.2	Small	<b>A</b>
Ø	Exposure to H <sub>2</sub> O after ② (180sec)	0.45±0.04	7.6±0.7	Small	<b>A</b>
(8)	Downflow treatment using H <sub>2</sub> O after ② (30sec)	0.28±0.01	4.7±0.2	None	Δ
	Downflow treatment using H <sub>2</sub> O after ② (90sec)	0.15±0.00	2.5±0.0	No	Δ
	Downflow treatment using H <sub>2</sub> O after ② (180sec)	0.11±0.01	1.9±0.1	No	Δ
	Downflow treatment using H <sub>2</sub> after ② (30sec)	0.68±0.01	11.8±0.2	Small	•
	Downflow treatment using H <sub>2</sub> O after ② (90sec)	0.68±0.01	11.7±0.1	Small	•
	Downflow treatment using H <sub>2</sub> after ② (180sec)	0.64±0.01	11.1±0.2	Small	▼

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## UNITED STATES PATENT AND TRADEMARK OFFICE **CERTIFICATE OF CORRECTION**

**PATENT NO.** : 5,397,432

Page 1 of 2

**DATED** 

: March 14, 1995 INVENTOR(S) : Konno, et al.

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Column 10-11, Table 1 should be deleted and substitute therefor the attached Table 1.

Signed and Sealed this

Nineteenth Day of January, 1999

Attest:

Acting Commissioner of Patents and Trademarks

Attesting Officer